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Fast and robust hydrogen sensors based on discontinuous palladium films on polyimide, fabricated on a wafer scale

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Abstract

Fast hydrogen sensors based on discontinuous palladium (Pd) films on supporting polyimide layers, fabricated by a cost-efficient and full-wafer compatible process, are presented. The films, deposited by electron-beam evaporation with a nominal thickness of 1.5 nm, consist of isolated Pd islands that are separated by nanoscopic gaps. On hydrogenation, the volume expansion of Pd brings initially separated islands into contact which leads to the creation of new electrical pathways through the film. The supporting polyimide layer provides both sufficient elasticity for the Pd nanoclusters to expand on hydrogenation and a sufficiently high surface energy for good adhesion of both film and contacting electrodes. The novel order of the fabrication processes involves a dicing step prior to the Pd deposition and stencil lithography for the patterning of microelectrodes. This allows us to preserve the as-deposited film properties. The devices work at room temperature, show response times of a few seconds and have a low power consumption of some tens of nW.

(Some figures in this article are in colour only in the electronic version)

1. Introduction

Hydrogen (H₂) has raised considerable interest as a future energy carrier in its application to fuel-cell-driven vehicles, as it is absolutely free of polluting emissions. Because it is flammable between concentrations of 4% and 75% in air, safety sensors for leak detection are required. In recent years, a variety of sensor concepts has emerged such as resistivity-based [1, 2], MOS-based [3, 4], optical [5], cantilever-based [6] or nanogap-based sensors [7, 8]. Most of these devices make use of palladium (Pd) as the sensitive material because of its highly catalytic surface and a large solubility of atomic hydrogen [9, 10]. To pave the way for commercial usage, such sensors need not only to be fast and sensitive below the lower explosion limit (LEL) of hydrogen in air, but also robust, reliable and manufacturable on large scales at low costs.

It has been shown that the use of ultrathin discontinuous Pd films [11] offers a simple solution to realize a hydrogen sensor that could fulfill many of those requirements. Discontinuous films are commonly deposited by physical vapor deposition (PVD) techniques such as electron-beam evaporation. Such films, being at an early stage of film growth, exhibit an island-like disconnected morphological structure and inherently include a multitude of nanoscopic gaps [12]. Inter-island distances are usually found to be in the range of a few nanometers. By exposing a discontinuous Pd film to hydrogen, the volume expansion of Pd [9, 10] leads to mechanical narrowing or even closing of the nanogaps, giving rise to the formation of new electrical pathways. This results in a decrease of the sensor resistance. Advantages of nanocrystalline films for hydrogen sensing are an increased solubility of hydrogen [13, 14], a larger volume increase [15–17] and less hysteresis [18] when compared with bulk palladium. Deposited on rigid substrates such as SiO₂, discontinuous Pd films showed poor hydrogen sensing.
results, due to an insufficient in-plane relaxation of mechanical stress which is built up during hydrogen absorption inside the Pd islands [19]. Xu et al. [11] showed highly improved sensing characteristics and fast response times by the use of an intermediate silane-based self-assembled monolayer (SAM). Here, the lower surface free energy of the SAM increased the surface mobility of the Pd clusters. However, the use of low surface energy substrates might entail poor adhesion of both the Pd film and connecting electrodes which could compromise the mechanical reliability of the devices in their application. We have previously shown that thin polymer films such as polyimide (PI) allow a palladium film to expand sufficiently for hydrogen sensing, while maintaining good adhesion properties [20]. Further, PI shows high chemical inertness, temperature stability up to several hundred degrees [21] and can easily be deposited by standard spin-coating processes. This makes it also interesting as a supporting layer for discontinuous Pd films.

In the present work we demonstrate a hydrogen sensor based on discontinuous palladium films on a supporting polyimide layer. The devices are manufacturable using simple and common microfabrication techniques and show a fast response to hydrogen well below the lower explosion limit of H2 in air, low power consumption in the nW range and good mechanical and temperature stability. The simple fabrication methods used and hence low manufacturing costs show a high potential for industrial purposes.

2. Fabrication

The sensor fabrication includes three main steps: (i) the deposition of the supporting polymer layer, (ii) the unmasked evaporation of the sensitive palladium film and (iii) the stencil-assisted deposition of the microelectrodes. To ensure that the film properties are preserved to a maximum extent, stencil lithography [22], a resistless deposition technique based on evaporation and shadow masking, is used to deposit the electrodes. To enable full-wafer compatible processing, full-wafer bulk silicon stencil masks are used which further provide good mechanical stability for handling (for further information on stencil fabrication, see supplementary information available at stacks.iop.org/Nano/21/505501/mmedia).

2.1. Process flow for sensor fabrication

The process flow for sensor fabrication is shown in figure 1(a). It starts with the deposition of the supporting PI film on a standard silicon wafer by spin-coating (step (i)). Large openings in the polymer layer can be defined by photolithography if the final gold wire bonding process after packaging requires a good mechanical strength of the bonds (step (ii)). Since metal adhesion on polymer surfaces is usually rather poor, the connecting metal electrodes are deposited across the structured polymer and the wire bonding can be carried out on top of the solid wafer surface. A wafer dicing process is performed prior to the palladium evaporation which separates the wafer into individual chips. This process order ensures that the fragile film is not exposed to either the cooling water jet that is used during dicing, or to mechanical vibrations that occur (step (iii)). A remaining thickness of 50 μm is left in the silicon since complete cutting would cause the dicing tape to relax. This would change the distance between the separated chips and impede the subsequent alignment of the stencil mask that includes the electrode design. The deposition of the Pd films is carried out using electron-beam evaporation at room temperature and an evaporation rate of 0.1 Å s⁻¹ (step (iv)). A low ambient pressure of 5 × 10⁻⁷ mbar is used in order to avoid excessive deposition of atmospheric residuals that can become significant for low evaporation rates [23]. The effective thickness of the films, as measured by a quartz balance, is 1.5 nm.

Now, the stencil mask is aligned to the wafer which still sticks to the dicing tape, and Ti/Al electrodes with various electrode spacings between 50 and 1000 μm are deposited (step (v) with details in figure 1(b)). Post-deposition of the electrodes makes sure that a good electrical contact to the discontinuous film is obtained and that no inhomogeneities in film properties arise at the electrode–film interface [24]. Figure 2(a) shows the pre-diced wafer and the stencil mask...
3. Results and discussion

3.1. Pd film properties

An SEM image of the 1.5 nm thick Pd film on a 2 \( \mu \text{m} \) thin polyimide layer is displayed in figure 2(d). The inset in the top left corner shows the difference in contrast between the blank PI surface and the additional Pd film. The Pd film consists of homogeneously distributed nanoclusters, roughly estimated to be around 10 nm in size by means of the SEM image. The significant surface roughness on the polyimide film did not permit AFM measurements that could resolve the contrast in the deposited Pd clusters. For DC bias voltages up to several volts, linear \( IV \) characteristics were obtained. This can be understood under the assumption of a multitude of tunnel junctions between the metal islands where a high external potential drop breaks up into small potential drops across each individual junction [25, 26]. An individual junction will then still be in the so-called low bias regime, where approximately linear \( IV \) behavior is obtained [27].

The relatively high surface free energy of the PI surface provides good adhesion properties of the Pd film. Ultrasonication at various frequencies \( f \) \( (f = 25 \text{ kHz}/45 \text{ kHz}/1 \text{ MHz}) \) up to 40 min were carried out and the electrical resistance of the films was measured. No significant changes before and after the treatment were observed, indicating that neither the Pd film nor the metal electrodes suffered damage. Similar experiments were performed on sensors using a self-assembled monolayer (Trichloro(1H, 1H, 2H, 2H-perfluorooctyl)silane) as a supporting layer. Xu et al [11] pointed out that a low surface free energy is advantageous for the ability of the Pd clusters to expand during hydrogen exposure. However, ultrasonication resulted in severe delamination of both the Pd film and the electrodes on our SAM layers, which made the sensors unusable.

Further, thermal annealing for a duration of 60 min and temperatures \( T \) increasing from \( T = 30 \) up to 200 °C was carried out in an oven under atmospheric conditions. No significant change in electric film resistance occurred up to temperatures of 150 °C. Above this, the film resistance increased rapidly, which we attribute to coalescence of the metal clusters. Initially separated islands start to agglomerate and the average inter-island distance within the film increases [19].

Temperature measurements in air revealed a negative temperature coefficient of resistance (TCR) which is typical for discontinuous metal films [28]. Together with electrical resistances in the MΩ range, it suggests a disconnected island-like morphological film structure. Therein, electric transport mechanisms such as thermally activated quantum tunneling between neighboring islands are likely to govern the film characteristics [12].

3.2. Characterization methods

Electrical measurements of the sensors in hydrogen were carried out using a sealed gas flow cell made out of
polymethylmethacrylate (PMMA) comprising an inlet for the hydrogen/nitrogen gas mixture and an outlet. Thereto, the sensor packages were mounted onto a printed circuit board (PCB) with electrical connections and placed inside the cell. A constant electric potential $V$ was applied and the current $I$ was measured by a picoampere meter. The hydrogen and nitrogen gas flow rates were controlled by calibrated mass flow meters and a flow controller (Vögtlin Instruments AG). In order to exclude cross-sensitivities caused by the N$_2$ carrier gas as well as the velocity of the gas flow, the devices were tested with pure N$_2$ and mixed H$_2$/N$_2$ flows at various flow rates between 25 and 200 ml min$^{-1}$. No changes in the electronic signals were observed.

3.3. Hydrogen sensing

Exposure of the sensors to H$_2}$/N$_2$ mixtures resulted in an instantaneous, sharp increase in electric current $\Delta I$ which saturated after a few seconds (see figure 3(a)). It showed a pronounced dependence on the H$_2$ concentration between concentrations of 0.5% and 4% H$_2$. The recovery time was in the range of some tens of seconds. No bias dependence on the sensor kinetics has been observed for moderate electrical potentials, here $1 \, V < \, V < \, 7 \, V$ (see the inset of figure 3(a)). As has likewise been reported for devices on other substrate materials such as glass, SiN or SAMs, we associate the decrease in electrical resistance that is observed with changes in inter-island distances and eventually mechanical closing of inter-island gaps. This densification of the film by the volume expansion of the Pd clusters triggers the formation of new electrical pathways that percolate through the film. The power consumption of the devices in air is in the range of some few tens of nW, which is related to the high electrical resistance.

Cyclic H$_2$/air exposures of the sensors revealed that the Pd film resistance is subject to irreversible changes. They appear as a reduction of current change $\Delta I$ with the number of cycles, following an exponential decrease of $\Delta I$ with increasing numbers of cycles (see figure 4 for the result of cyclic exposures to 4% H$_2$). The presence of such priming effects can, for instance, be the result of mechanical reorganization of the nanoclusters or breaking of connections between initially connected islands caused by the lattice dilatation and contraction [7]. Further, uptake of hydrogen in deep energy traps at grain boundaries may cause irreversible strain in the material [29]. Reproducible measurements can hence only be carried out when no further drift of the sensor response is guaranteed. For the present sensors this was the case after approximately 20 cycles.

Deviations from the exponential trend in signal decrease are observed when the sensor is exposed to ambient air for a longer time period. The hydrogen response following a longer exposure to air (see data points I, II and III in figure 4 for the first, sixth and eighth cycle, respectively) shows a reduced $\Delta I$ as compared to what is predicted by the trend curve. Since
subsequent cycles fall back on the original exponential trend we associate this observation by two main effects: (i) adsorbed oxygen on the palladium surface that is reduced by hydrogen molecules to form water and (ii) the presence of a thin water film in air which desorbs under the influence of the dry H₂/N₂ gas flow. After leaving the sensor under a constant N₂ flow during 12 h, this effect does not occur, which confirms the hypothesis.

Figure 3(b) shows concentration measurements for various electrode spacings $d$. All the plots follow a sigmoidal shape fit, suggesting that percolation is an important factor in the electronic transport process [8, 30]. However, a change in geometrical dimensions of the film by choosing electrodes with different spacings $d$ does not reveal any significant dependence. According to a recent theoretical study from our group on percolation in rectangular domains, only minor changes in conduction behavior can be expected by such geometrical changes [30] which indicates that our experimental findings could in fact be anticipated. Yet, with the choice of closer electrode spacings an overall decrease in electrical resistance can be obtained while similar sensing performances are maintained. This in turn allows the use of relatively simple electronic equipment for signal readout, which is highly desirable for integrated sensor applications.

3.4. Conclusions

Discontinuous palladium (Pd) films, created by electron-beam evaporation on supportive polyimide layers, were used for the cost-efficient fabrication of fast and robust hydrogen sensors. The dedicated process order and the use of stencil lithography allowed for full-wafer fabrication while preserving the as-deposited film properties. Thereafter, chip separation by dicing is performed before the film deposition and stencil lithography is used to deposit Ti/Al electrodes on top. The polyimide layer ensures both very good mechanical stability of the Pd films and electrodes, and the necessary flexibility for in-plane relaxation of hydrogen-induced stress in the Pd nanoclusters. The films withstand ultrasonication and temperatures up to 150 °C without significant changes in electrical resistance. The devices work at room temperature and detect hydrogen well below hydrogen concentrations of 4% within a few seconds and a power consumption of some tens of nW. Priming the sensor by alternating hydrogen/air cycles showed improvement in the reproducibility of the sensor response.

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